# Supplementary Information for 

# Gas-Phase Formation of Silicon Monoxide via NonAdiabatic Reaction Dynamics and its Role as a Building Block of Interstellar Silicates 

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Tables S1 to S5
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References

Table S1. Peak velocities $\left(\mathrm{V}_{\mathrm{p}}\right)$ and speed ratios $(S)$ of the silicon $(\mathrm{Si})$, and oxygen $\left(\mathrm{O}_{2}\right)$ beams along with the corresponding collision energies $\left(E_{\mathrm{C}}\right)$ and center-of-mass angles $\left(\Theta_{\mathrm{CM}}\right)$.

| Beam | $\mathrm{V}_{\mathrm{p}}$ <br> $\left(\mathrm{m} \mathrm{s}^{-1}\right)$ | $S$ | $E_{\mathrm{C}}$ <br> $\left(\mathrm{kJ} \mathrm{mol}^{-1}\right)$ | $\Theta_{\mathrm{CM}}$ <br> $($ degree $)$ |
| :---: | :---: | :---: | :---: | :---: |
| $\operatorname{Si}\left({ }^{3} \mathrm{P}\right)$ | $952 \pm 15$ | $6.1 \pm 0.6$ |  |  |
| ${ }^{18} \mathrm{O}_{2}\left(\mathrm{X}^{3} \Sigma^{-}\right)$ | $760 \pm 20$ | $13.8 \pm 1.0$ | $11.7 \pm 0.5$ | $46.5 \pm 1.2$ |

Table S2. The root-mean-square deviation (RMSD) of each TOF of single channel and twochannel fit.

|  | Single channel fit | Two-channel fit |
| :---: | :---: | :---: |
| $22.25^{\circ}$ | 6.43 | 6.05 |
| $28.25^{\circ}$ | 5.11 | 4.38 |
| $34.25^{\circ}$ | 2.95 | 2.83 |
| $40.25^{\circ}$ | 2.16 | 2.25 |
| $46.25^{\circ}$ | 3.31 | 3.51 |
| $52.25^{\circ}$ | 2.61 | 2.77 |

Table S3. The relative energies (in $\mathrm{kJ} \mathrm{mol}^{-1}$ ) of products, intermediates, and transition states with respect to the separated reactants $\left(\mathrm{Si}\left({ }^{3} \mathrm{P}\right)+\mathrm{O}_{2}\left(X^{3} \Sigma_{g}^{-}\right)\right)$.

|  | Experimental ${ }^{1}$ | $\operatorname{CCSD}(\mathrm{T}) / \mathrm{CBS}^{2}$ | $\begin{gathered} \hline \text { CASSCF/Def2- } \\ \text { TZVP }{ }^{3} \\ \hline \end{gathered}$ | $\begin{gathered} \hline \text { MRCI/Def2- } \\ \text { TZVP }^{c} \end{gathered}$ |
| :---: | :---: | :---: | :---: | :---: |
| $\begin{gathered} \operatorname{SiO}\left(X^{1} \Sigma^{+}{ }^{\mathbf{O}}\right)+ \\ \mathbf{O}\left({ }^{3} \mathbf{P}\right) \end{gathered}$ | -301 | -301 | -384 | -303 |
| $\begin{gathered} \operatorname{SiO}\left(X^{1} \Sigma^{+}\right)+ \\ \mathbf{O}\left({ }^{1} \mathbf{D}\right) \end{gathered}$ | -112 | -90 | -174 | -107 |
| i1 |  |  | -473 | -420 |
| 12 |  |  | -160 | -99 |
| 13 |  |  | -407 | -410 |
| 14 |  |  | -648 | -650 |
| 15 |  |  | -255 | -183 |
| TSr2 |  |  | 39 | 66 |
| TS14 |  |  | -366 | -352 |
| TS15 |  |  | -226 | -132 |
| TS2p |  |  | -153 | -93 |
| TS3p |  |  | -332 | -271 |

Note:
Experimental heat of reaction is computed from the heat of formation ${ }^{1-3}$.
${ }^{2}$ Geometries and ZPEs are calculated at $\operatorname{CCSD}(\mathrm{T}) / \mathrm{cc}-\mathrm{pVTZ}$ level. CBS are extrapolated from 3-, 4-, and 5-zeta basis sets.
${ }^{3}$ Geometries and ZPE are calculated at CASSCF/Def2-TZVP level.

Table S4. The relative energies (in $\mathrm{kJ} \mathrm{mol}^{-1}$ ) of the lowest singlet and triplet electronic state of intermediates and transition states with respect to the separated reactants ( $\mathrm{Si}\left({ }^{3} \mathrm{P}\right.$ ) $+\mathrm{O}_{2}\left(\mathrm{X}^{3} \Sigma_{g}^{-}\right)$. The first column indicates whether the species is optimized on the singlet $(\mathrm{S})$ or triplet ( T ) surface.

|  | Optimal Structure on Surface | Singlet Energy | Triplet Energy |
| :---: | :---: | :---: | :---: |
| i1 | S | -425 | -179 |
| i2 | T | -151 | -101 |
| $\mathbf{i 3}$ | T | -464 | -415 |
| $\mathbf{i 4}$ | S | -660 | -161 |
| i5 | S | -186 | 32 |
| TSr2 | T | 51 | 66 |
| TS14 | S | -351 | -384 |
| TS15 | S | -133 | -86 |
| TS2p | T | -131 | -90 |
| TS3p | T | -247 | -270 |

Table S5. The point group, electronic state, and geometric parameters of each stationary point.

| Structure | $8$ |  | $\mathrm{O}-\mathrm{C}$ |  |  |  | $\sigma_{0}$ |  |
| :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: |
| Name | i1 | i3 | 14 | TS14 | TS3p | MSX-a1 | MSX-a2 | MSX-c |
| Point Group | $\mathrm{C}_{2 \mathrm{v}}$ | $\mathrm{C}_{2 \mathrm{v}}$ | $\mathrm{D}_{\text {oh }}$ | $\mathrm{C}_{2 \mathrm{v}}$ | $\mathrm{C}_{\mathrm{s}}$ | $\mathrm{C}_{2 \mathrm{v}}$ | $\mathrm{C}_{2 \mathrm{v}}$ | $\mathrm{C}_{\text {s }}$ |
| Electronic State | ${ }^{1} \mathrm{~A}_{1}$ | ${ }^{3} \mathrm{~B}_{2}$ | ${ }_{1} \Sigma_{g}^{+}$ | ${ }^{1} \mathrm{~A}_{1}$ | ${ }^{3} \mathrm{~A}$ " | - | - | - |
| O-Si-O Bond Angle ( ${ }^{\circ}$ ) | 58.42 | 110.83 | 180.00 | 96.81 | 119.56 | 86.71 | 104.68 | 114.4 |
| Si-O Bond Length (pm) | 166.4 | 159.7 | 151.4 | 166.6 | 152.6 | 166.1 | 161.4 | 152.8 |
| Si-O Bond Length (pm) | 166.4 | 159.7 | 151.4 | 166.6 | 214.6 | 166.1 | 161.4 | 203.2 |
| Structure |  | $\bigcirc$ | $09$ |  |  | $\cdots$ | 0 | $\bigcirc$ |
| Name | i2 | i5 | TSr2 | TS15 | TS2p | SiO | $\mathrm{O}_{2}$ | MSX-b |
| Point Group | $\mathrm{C}_{\text {s }}$ | $\mathrm{C}_{\text {ov }}$ | $\mathrm{C}_{\mathrm{s}}$ | $\mathrm{C}_{\text {s }}$ | $\mathrm{C}_{\text {s }}$ | $\mathrm{C}_{\text {cov }}$ | $\mathrm{D}_{\text {oh }}$ | $\mathrm{C}_{\text {ov }}$ |
| Electronic State | ${ }^{3}$ A" | ${ }_{15}{ }^{+}$ | ${ }^{3}$ A" | ${ }^{1} \mathrm{~A}$, | ${ }^{3} \mathrm{~A}$ " | ${ }^{1} \mathrm{~A}_{1}$ | ${ }_{3} \Sigma_{g}^{-}$ | - |
| Si-O-O Bond Angle ( ${ }^{\circ}$ ) | 110.40 | 180.00 | 118.68 | 121.41 | 109.98 | - | - | 180.00 |
| Si-O Bond Length (pm) | 170.9 | 151.8 | 253.5 | 153.0 | 164.7 | 152.2 | - | 151.7 |
| O-O Bond Length (pm) | 141.1 | 144.2 | 124.0 | 159.9 | 157.7 | - | 121.7 | 170.7 |




Flight Time ( $\mu \mathrm{s}$ )
Figure S1. Laboratory angular distribution (top) and time-of-flight (TOF) spectra (bottom) recorded at $m / z=46$ for the reaction of the silicon atom ( $\mathrm{Si} ;{ }^{3} \mathrm{P}$ ) with molecular oxygen $\left({ }^{18} \mathrm{O}_{2} ; \mathrm{X}^{3} \Sigma_{g}^{-}\right)$. The data were fit with two channels: i) ${ }^{28} \mathrm{Si}\left({ }^{3} \mathrm{P} ; 28 \mathrm{amu}\right)+{ }^{18} \mathrm{O}_{2}\left(\mathrm{X}^{3 \Sigma_{g}^{-}} ; 36 \mathrm{amu}\right) \rightarrow{ }^{28} \mathrm{Si}^{18} \mathrm{O}\left(\mathrm{X}^{1 \Sigma}{ }^{+} ; 46 \mathrm{amu}\right)+{ }^{18} \mathrm{O}\left({ }^{3} \mathrm{P} ; 18\right.$ $\mathrm{amu})$ (green), ii) ${ }^{28} \mathrm{Si}\left({ }^{3} \mathrm{P} ; 28 \mathrm{amu}\right)+{ }^{18} \mathrm{O}_{2}\left(\mathrm{X}^{3 \Sigma_{g}^{-}} ; 36 \mathrm{amu}\right) \rightarrow{ }^{28} \mathrm{Si}^{18} \mathrm{O}\left(\mathrm{X}^{1 \Sigma^{+}} ; 46 \mathrm{amu}\right)+{ }^{18} \mathrm{O}\left({ }^{1} \mathrm{D} ; 18 \mathrm{amu}\right)$ (blue), with branching ratios of $33 \%$ (channel i) and $67 \%$ (channel ii), respectively. CM represents the center-of-mass angle, and $0^{\circ}$ and $90^{\circ}$ define the directions of the silicon atom and molecular oxygen beams, respectively. The black circles depict the experimental data, and colored lines the fits (red corresponding to the total fit).


Figure S2. The intrinsic reaction coordinate (IRC) demonstrating that TSr2 connects to the separated reactants and i2. The energies is in $\mathrm{kJ} \mathrm{mol}^{-1}$ calculated with CASSCF/def2-TZVP (upper figure) and the geometrical parameters are pm and degree (lower figure).

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